

INFORMATION DISCLOSURE STATEMENT

Applicant : Hojo, et al.
App. No : 10/553,083
Filed : October 11, 2005
For : POSITIVE RESIST COMPOSITION
AND METHOD OF FORMATION OF
RESIST PATTERN
Examiner : C. Hamilton
Art Unit : 1752

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I hereby certify that this correspondence, and any other attachment noted on the automated Acknowledgement Receipt, is being transmitted from within the Pacific Time zone to the Commissioner for Patents via the EFS Web server on:

November 29, 2007

(Date)

Neil S. Battfeld, Ph.D., Reg. No. 39901

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

Enclosed for filing in the above-identified application is a PTO/SB/08 Equivalent listing 3 references to be considered by the Examiner. The 2 foreign patent references and/or non-patent literature as listed on the Information Disclosure Statement are not enclosed since they were previously filed on October 2, 2007.

This Information Disclosure Statement is being filed before the receipt of a first Office Action on the merits, and presumably no fee is required. If a first Office Action on the merits was mailed before the mailing date of this Statement, the Commissioner is authorized to charge the fee set forth in 37 C.F.R. § 1.17(p) to Deposit Account No. 11-1410.

Respectfully submitted,

KNOBBE, MARTENS, OLSON & BEAR, LLP

Dated: 11/29/07

By: Neil S. Battfeld

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